Effect of Silane Coating on the Corrosion Resistance of TiO$_2$ Conversion Films

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TiO$_2$ conversion films were prepared on surfaces undergoing the hot-dip galvanizing (HDG) process using titanium sulphate (Ti(SO$_4$)$_2$) as the titanium source and hydrogen peroxide (H$_2$O$_2$) as the chelating agent by a one-step impregnation method. The effect of passivation time on the morphology and corrosion resistance of the film was investigated. The results show that a large amount of TiO$_2$ nanospheres appear on the HDG surface after a short immersion time. By increasing the immersion time, the nanospheres are gradually covered by the ZnO/Zn(OH)$_2$ conversion film, and some cracks appear on the conversion film. The electrochemical results reveal that the integral TiO$_2$ conversion film shows better corrosion resistance, and the cracks cause the pitting of the corrosion resistance. To improve its corrosion resistance, the TiO$_2$ conversion film was modified by silane to realize hydrophobic sealing, which results in obvious changes in the morphology and corrosion resistance. After modification, the gel layer covered the TiO$_2$ conversion film, which would fill the cracks and make the film hydrophobic. Thus, the corrosion resistance of the modified conversion film increased. The better the hydrophobicity of the film is, the better the corrosion resistance of the film is for a short immersion time. In addition, the corrosion resistance of the hydrophobic film is mainly determined by the bottom TiO$_2$ conversion film.

Keywords: TiO$_2$; Hydrophobic; Conversion film; Corrosion resistance; Silane

1. INTRODUCTION

The hot-dip galvanizing (HDG) process is an effective technology that can protect steel from corrosion and increase the service life of steel. However, it is easy for the HDG process to produce white rust at ambient conditions or during the transportation process, which affects its appearance and life[1]. Hexavalent chromium passivation is the easiest and most economical way to improve the corrosion resistance of HDG coatings, but it has been banned because it is toxic and pollutes the environment. Chromium-free passivation technology is an alternative method that has received
increasing attention[2]. Chromium-free passivation is mainly classified into inorganic salt passivation, organic passivation, and organic/inorganic hybrid passivation. Inorganic salt passivation mainly includes silicate[3], molybdate[4], and rare earth salts[5]. Organic passivation mainly consists of phytic acid[6], acrylic resin[7], and silane[8].

Titanium (Ti) is very similar in nature to chromium and is stable in the natural environment resulting from the robust TiO$_2$ formed on the Ti surface. The Ti(OH)$_2$/TiO$_2$ film, as an environmentally friendly type of chromium-free conversion film, is formed on the HDG surface, which could effectively improve the corrosion resistance of the matrix. Many researchers have studied the formation mechanism of titanium conversion films on steel[9], copper[10], and magnesium alloys[11]. They found that TiO$_2$ conversion films could effectively improve the corrosion resistance of these alloys. However, as far as we know, few works have focused on the formation of TiO$_2$ conversion films on the HDG surfaces[7].

TiO$_2$ passivation can improve the corrosion resistance of the galvanized layer. However, there are some cracks on the surface of the conversion film that affect the corrosion resistance of the film. The hybrid or sealing treatment can solve this problem to some extent[12]. Simultaneously, the hydrophobic treatment can increase the corrosion resistance of the conversion film[13]. In this paper, a layer of TiO$_2$ conversion film with a certain degree of roughness was prepared on the HDG surface, and the effects of the treatment time on the morphology and corrosion resistance of the film were investigated. Then, the hydrophobic sealing treatment was used to improve corrosion resistance of the conversion film. the effects of silane treatment on the morphology, water repellency and corrosion resistance were explored.

2. EXPERIMENTAL

TiO$_2$ conversion solution was prepared by adding 1 g of Ti(SO$_4$)$_2$ and 60 mL of 30% H$_2$O$_2$ into 940 mL of deionized water. The pH of the solution was adjusted to 2.0 by a 1 M H$_2$SO$_4$ solution.

The silane-modified solution was prepared via the sol-gel method, using TEOS (tetraethoxysilane) as a precursor, EtOH as a solvent, and HMDS (hexamethyldisiloxane) as a modification component. The molar ratio of the solution was TEOS/HMDS/C$_2$H$_5$OH/H$_2$O = 1:2:96:4[14]. First, the TEOS, EtOH, and distilled water were mixed by vigorous stirring for 12 h at room temperature. Then, HMDS was added into the mixed solution. After that, the solution was aged for 2 h at 80 °C.

The hydrolysis reaction of TEOS and HMDS are shown in Eq. (1) and (2):

\[
\text{Si(OCH}_2\text{CH}_3\text{)}_4 + \text{H}_2\text{O} \rightarrow \text{Si(OH)}_n\text{(OCH}_2\text{CH}_3\text{)}_m \quad n+m=4
\]

(1)

\[
(\text{CH}_3)_3\text{SiNH(CH}_3\text{)}_3 + \text{H}_2\text{O} \rightarrow 2(\text{CH}_3)_3\text{Si-OH} + \text{NH}_3
\]

(2)

Simultaneously, the polymerization reactions happen between the hydrolysis products of TEOS and HMDS, the modification solution is formed.

\[
\text{Si(OH)}_n\text{(OCH}_2\text{CH}_3\text{)}_m + (\text{CH}_3)_3\text{Si-OH} \rightarrow \text{Si(OH)}_3\text{Si(A)}_3
\]

A: ((\text{CH}_3)_3\text{SiO})_x(\text{SiO})_y(\text{OH}) \quad x, y>1, \text{integer}

(3)
The HDG substrate (zinc layer thickness of approximately 50 μm) was prepared using the following process. Q235 cold rolled steel sheets of 50 mm × 40 mm × 2 mm were degreased, pickled and then fluxed in a mixed solution of 150 g/L NH₄Cl and 100 g/L ZnCl₂ at 60 °C. The samples were dried and dipped in a zinc bath at 450 °C for 1 min, and then, they were withdrawn slowly and quenched in water immediately. Prior to immersion, the HDG samples were rinsed with ethanol and deionized water.

HDG samples were immersed at ambient temperature for 10 s, 60 s, 300 s, and 1800 s in TiO₂ conversion solution, respectively. After immersion, the samples were dried at 120 °C for 30 min. The samples were named T10, T60, T300, and T1800, respectively. Furthermore, the conversion films were immersed into the silane-modified solution for 2 hours and then dried at 120 °C for 30 min. The silane-modified conversion films were named as T10M, T60M, T300M, and T1800M, respectively.

The morphologies of the samples were observed using a higher resolution scanning electron microscope (SEM, Nanosem 430, Nova, USA). The chemical composition of the surface was analysed by using an energy-dispersive spectrometer (EDS, X'Pert Pro, Philips, Netherlands). The coatings were also investigated by X-ray diffraction analysis (XRD, XPert Pro, Philips, Netherlands) and X-ray photoelectron spectroscopy (XPS, PHI-5702, Perkin Elmer, USA). The water contact angles (WCAs) of the coatings were obtained by using an optical contact angle metre (OCA15, DataPhysics Instruments GmbH, Germany) with a 5 µL water droplet at room temperature (∼26 °C).

The potentiodynamic polarization (PDP) and electrochemical impedance spectroscopy (EIS) measurements were used to evaluate the corrosion resistance of the samples in a 5 wt.% NaCl solution. A three-electrode system (Model: 760C) was constructed to serve as the electrochemical reactor, in which a saturated calomel electrode (SCE) acted as the reference electrode, a platinum foil acted as the auxiliary electrode and the sample with an exposed area of 1.00 cm² acted as the working electrode. EIS tests were carried out in a frequency range between 100 kHz and 10 mHz by applying an AC excitation of 10 mV amplitude of sinusoidal voltage. The scan rate for polarization was 1 mV/s. The EIS data of samples were evaluated using the ZView software (version 2.1C)[15]. The PDP tests were recorded from -0.2 V (vs. OCP, open circuit potential) to +0.2 V (vs. OCP) with a scan rate of 1 mV/s.

3. RESULTS AND DISCUSSION

3.1. XPS

The conversion film sample with good corrosion was chosen to analyse the components. Fig. 1 is the XPS spectrum of T60 and the spectra of Zn2p and Ti2p. The conversion film is composed of the elements Zn, O, and Ti (Fig. 1a), element C comes form pollution. The Zn2p spectrum (Fig. 1b) exhibits two peaks at 1021.61 eV (Zn2p3/2) and 1022.70 eV (Zn2p3/2), which are attributed to ZnO and Zn(OH)₂[16]. Simultaneously, the Ti2p spectrum (Fig. 1c) exhibits two peaks at 458.28 eV (Ti2p3/2) and 463.96 eV (Ti2p1/2) corresponding to TiO₂ and Ti(OH)₄[17]. It is shown that after passivation treatment, the conversion films with Ti(OH)₄/TiO₂ and ZnO/Zn(OH)₂ have been formed on the HDG surface.
Figure 1. XPS spectra of (a) T60, (b) Zn2p, and (c) Ti2p.

3.2. XRD

Figure 2. XRD spectra of the T60 and T60M samples.

The XRD patterns of T60 and T60M are shown in Fig. 2. The pattern of T60 (Fig. 2a) shows a strong peak at 36.3° according to the (002) planes of zinc\textsuperscript{18}. From the enlarged pattern (Fig. 2b), it can...
been found that there are two peaks at 54.1° and 55° for T60 and T60M, which can be assigned to the (105) and (211) planes of TiO$_2$ with anatase phase (according to the JCPDS standards, Card No. 21-1272[19]), respectively. However, the intensity of the TiO$_2$ peak decrease after silane treatment. The XRD plots of T60M (Fig. 2c) display that a diffraction peak at 2θ=18° is attributed to the amorphous SiO$_2$[20]. The results indicate that after the sealing with silane, the amorphous silane gel layer covers the TiO$_2$ conversion film surface.

3.3. Morphology of TiO$_2$ and silane-modified conversion films on HDG surfaces

SEM images (Fig. 3) show the surface morphologies of TiO$_2$ conversion films on HDG surfaces with different immersion times in the Ti(SO$_4$)$_2$ solution.

Table 1. EDS data of different areas showing the elemental components for TiO$_2$ conversion films.

<table>
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<th>Points</th>
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<th>Elements</th>
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<td>8</td>
<td>Atomic%</td>
<td>80.16</td>
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</table>

Table 1 is the EDS data obtained from different red regions in Fig. 3. It can be found that after 10 s of treatment (Fig. 3a), the conversion film with an abundance of powder is formed on the HDG surface. After 60 s of reaction, a relatively smoother film is formed on the HDG surface (Fig. 3b). Some nanoparticles can also be found on the film. From the magnified SEM image in Fig. 3b, the aggregations are rough round particles. When the immersion time increases to 300 s, the thickness of the conversion film is thicker, and a few small cracks occur resulting from the surface stress (Fig. 3c). When the immersion time is increased to 1800 s, the cracks become larger, and some conversion film has peeled off (Fig. 3d). The roughness of the conversion film increases with an increase of the passivation time. From the EDS data, the smooth region (regions 1, 3, 5, 7) comprised Zn and O elements. The aggregations (region 2, 4, 6, 8) consist of Zn, O, and Ti elements and are TiO$_2$-rich. From the XPS and XRD result, it can be determined that the smooth region and aggregation are ZnO/Zn(OH)$_2$ and TiO$_2$-rich, respectively.
Figure 3. SEM images showing the surface morphologies of (a) T10, (b) T60, (c) T300, and (d) T1800.

The formation process of the conversion film can be concluded to occur as follows: when the HDG was dipped into the passivation solution, a displacement reaction occurs between Zn and H\(^+\), and a depolarization reduction reaction occurs between H\(^+\) ions and O\(_2\)[21]. The chemical decomposition reaction of H\(_2\)O\(_2\) provides O\(_2\) to the solution and further produces more OH\(^-\) ions, which promotes the increase in the pH value of the solution. The reactions may occur as follows[22]:

\[
\begin{align*}
\text{Zn} + 2\text{H}^+ &\rightarrow \text{Zn}^{2+} + \text{H}_2 \\
\text{O}_2 + 2\text{H}_2\text{O} + 4e^- &\rightarrow 4\text{OH}^- 
\end{align*}
\]

(4)

(5)

The increasing amount of OH\(^-\) ions provides the conditions to form Ti(OH)\(_4\) and Zn(OH)\(_2\). When the pH of the small region is larger than 2.5, the deposition of Ti\(^{4+}\) induces the formation of Ti(OH)\(_3\)/TiO\(_2\)[23]. Simultaneously, Li\(^{[17]}\) reported that the Ti\(^{4+}\) ions that come from the Ti(SO\(_4\))\(_2\) combine with the OH\(^-\) to form the TiO\(_2\) nanoparticles in weak alkaline conditions, and thus, the TiO\(_2\) nanoparticles preferentially deposit onto the HDG surface. The formation of TiO\(_2\) nanoparticles may occur as follows:

\[
\begin{align*}
[\text{Ti(OH)}_2\cdot(\text{H}_2\text{O})_4]^{2+} + 2\text{OH}^- &\rightarrow [\text{Ti(OH)}_4\cdot(\text{H}_2\text{O})_2] + 2\text{H}_2\text{O} \\
[\text{Ti(OH)}_4\cdot(\text{H}_2\text{O})_2] &\rightarrow \text{TiO}_2 \cdot 4\text{H}_2\text{O}
\end{align*}
\]

(6)

(7)
When the pH of the small region is larger than 8, Zn(OH)$_2$/ZnO deposits on the HDG surface[24], which covers the TiO$_2$ nanoparticles to form the smooth conversion film. The formation of the Zn(OH)$_2$/ZnO layer may be written as follows:

\[
\begin{align*}
\text{Zn}^{2+} + 2\text{OH}^- & \rightarrow \text{Zn(OH)}_2 \quad (8) \\
\text{Zn(OH)}_2 & \rightarrow \text{ZnO} + \text{H}_2\text{O} \quad (9)
\end{align*}
\]

From the SEM (Fig. 3) and EDS (Table 1) results, it can be determined that after 10 s of reaction, the TiO$_2$ nanoparticles are first formed on the HDG surface. The formation of Zn(OH)$_2$/ZnO is lagging, and the layer of Zn(OH)$_2$/ZnO is relatively thin so that it cannot cover the TiO$_2$ nanoparticles completely. By increasing the immersion time, a dense Zn(OH)$_2$/ZnO layer could cover the TiO$_2$ nanoparticles. It can be noted that the TiO$_2$ nanoparticles have been inserted into the conversion film. With further increases in the immersion time, the denser layer begins to crack due to internal stress[25].

**Table 2.** EDS data of different areas showing the elemental components of silane-modified conversion films.

<table>
<thead>
<tr>
<th>Points</th>
<th>Content</th>
<th>Elements</th>
</tr>
</thead>
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<tr>
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<td>Atomic%</td>
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<tr>
<td>2</td>
<td>Atomic%</td>
<td>32.13</td>
</tr>
<tr>
<td>3</td>
<td>Atomic%</td>
<td>35.11</td>
</tr>
<tr>
<td>4</td>
<td>Atomic%</td>
<td>29.78</td>
</tr>
<tr>
<td>5</td>
<td>Atomic%</td>
<td>29.78</td>
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<tr>
<td>6</td>
<td>Atomic%</td>
<td>13.60</td>
</tr>
<tr>
<td>7</td>
<td>Atomic%</td>
<td>11.56</td>
</tr>
<tr>
<td>8</td>
<td>Atomic%</td>
<td>17.00</td>
</tr>
</tbody>
</table>

Fig. 4 shows the surface morphologies of silane-modified conversion films. After modification, all the conversion films are relatively smooth, and the cracks disappear. The EDS results (Table 2) display that the flat regions of the modified films are comprised of the elements O, C, Si, and Zn, and the particles contain the elements O, C, Si, Zn, and Ti. The results demonstrate that after the modification process, the TiO$_2$ conversion film has been covered by a silane gel layer[26]. A large number of hydroxyl groups exist on the TiO$_2$ conversion film, and when the conversion films is immersed into the modification solution, dehydration synthesis occurs between the conversion film and solution[26]. The reactions between the conversion film and silane modification solution may be written as Eq. (10) and (11). A layer of SiO$_2$ layer with hydrophobic groups forms on the TiO$_2$ conversion film.

\[
\begin{align*}
\text{-O-Ti-OH+Si(OH)₃-Si(A)₃} & \rightarrow \text{-O-Ti-O-Si(OH)₂O-Si(A)₃} \quad (10)
\end{align*}
\]
\[ -\text{O}-\text{Zn-OH} + \text{Si(OH)}_3 - \text{Si(A)}_3 \rightarrow -\text{O}-\text{Zn-O-Si(OH)}_2 - \text{Si(A)}_3 \]

A: \((\text{CH}_3)_3\text{SiO})_x\texttt{(SiO)}_y(\text{OH})\quad x, y > 1\), integer

Figure 4. SEM images showing the surface morphologies of (a) T10M, (b) T60M, (c) T300M, and (d) T1800M.

3.3. Effect of silane modification on the water repellence of the conversion film

Fig. 5 shows the WCAs of TiO₂ conversion films and silane-modified films. The WCA of T10 is 70° (Fig. 5a), which is similar with that of pure zinc\(^{[27]}\). T60 has a WCA of 25° (Fig. 5b) because a large amount of hydroxyl groups exist in the TiO₂ conversion film. The WCAs of T300 and T1800 are 15° and 9° (Fig. 5c-d), respectively, indicating that prolonging the passivation time causes a decrease in the hydrophobicity of the TiO₂ conversion films. The reason is that the roughness of the coating increases as the passivation time increases. Simultaneously, the film is hydrophilic. From the Wenzel equation\(^{[28]}\), as shown in Eq. (12), where \( \theta \) is the apparent contact angle on the conversion film, \( r \) is the surface roughness and \( \theta_0 \) is the equilibrium contact angle on the smooth zinc, it can be seen that as the roughness of the conversion film increases, the WCA of the hydrophilic film decreases.
Fig. 5. WCA images of (a) T10, (b) T60, (c) T300, (d) T1800, (e) T10M, (f) 60M, (g) T300M, and (h) T1800M.

\[
\cos \theta = r \times \cos \theta_0 \tag{12}
\]

Fig. 5e is the WCA image of T10M. The silane-modified film becomes hydrophobic with a WCA of 102.9° as a low surface material modification. Similarly, the WCA values of T60M, T300M and T1800M are 122°, 128°, and 131° (Fig. 5f-h), respectively. The roughness of the film increases with an increased immersion time, which results in the stronger hydrophobicity of the modified films. The results are consistent with the typical Wenzel model[28].

3.4. Anti-corrosion performance

3.4.1 Anti-corrosion performance of TiO₂ conversion films

Table 3. Electrochemical parameters obtained on the TiO₂ conversion films

<table>
<thead>
<tr>
<th>Samples</th>
<th>( I_{\text{corr}} ) (μA/cm²)</th>
<th>( E_{\text{corr}} ) V vs. SCE</th>
<th>( R_p ) (Ω·cm²)</th>
<th>( b_a ) (mV/decade)</th>
<th>( b_c ) (mV/decade)</th>
</tr>
</thead>
<tbody>
<tr>
<td>T10</td>
<td>1.05</td>
<td>-1.143</td>
<td>8679</td>
<td>42.25</td>
<td>-40.27</td>
</tr>
<tr>
<td>T60</td>
<td>0.55</td>
<td>-1.037</td>
<td>12843</td>
<td>68.87</td>
<td>-21.32</td>
</tr>
<tr>
<td>T300</td>
<td>4.20</td>
<td>-1.102</td>
<td>2309</td>
<td>46.28</td>
<td>-43.20</td>
</tr>
<tr>
<td>T1800</td>
<td>15.37</td>
<td>-1.109</td>
<td>581</td>
<td>45.90</td>
<td>-37.23</td>
</tr>
</tbody>
</table>

PDP and EIS were employed to evaluate the corrosion protection performance and to provide insight on the corrosion mechanism of the TiO₂ and hydrophobic conversion films. Fig. 6 shows the PDP curves of TiO₂ conversion films with different immersion times in the Ti(SO₄)₂ solution. Table 3 shows the fitted results from Fig. 6. The corrosion current \( (i_{\text{corr}}) \) for T60 is minimal, approximately 0.55 μA/cm², and the \( i_{\text{corr}} \) for T10 is 1.05 μA/cm². The \( i_{\text{corr}} \) for T300 and T1800 samples decrease
compared to those for T10 and T60, the lower the $i_{corr}$, the lower corrosion rate for conversion film in the solution[29]. The anodic and cathodic branches for T300 and T1800 move towards the direction of a current increase compared with that of T60. Due to the existence of cracks for T300 and T1800, the corrosion medium can permeate through the conversion film, and the corrosion reaction occurs on the HDG surface, which results in decreases in the corrosion resistance of samples. Among the conversion films, T60 exhibits better protective properties relative to T10, T300, and T1800. The $i_{corr}$ of T1800 is similar to that of pure zinc[30], indicating that the cracks are a disadvantage to determine the corrosion resistance of the conversion films.

![Potentiodynamic polarization curves](image1)

**Figure 6.** Potentiodynamic polarization curves for TiO$_2$ conversion films with different immersion times in 5 wt.% NaCl solution.

![EIS plots](image2)

**Figure 7.** EIS (a) Nyquist plots and (b) Bode plots (log $|Z|$ Vs log Freq and phase angle vs log Freq) for TiO$_2$ conversion films in a 5 wt.% NaCl solution.
The Nyquist and Bode diagrams for the conversion films immersed in 5 wt.% NaCl are shown in Fig. 7. The corrosion resistance can also be calculated from the total impedance values \(|Z|_{|j→0}\). The higher the \(|Z|_{|j→0}\), the lower corrosion rate for conversion film in the solution[29]. The value of \(|Z|_{|j→0}\) for T10 and T60 are 1.04 \times 10^4 \Omega \text{ cm}^2 and 1.06 \times 10^4 \Omega \text{ cm}^2, respectively. The value of \(|Z|_{|j→0}\) for the T60 sample is higher than those of the T300 and T1800 samples. The results are in good agreement with the results of PDP and further indicate that the corrosion resistance decreases with the increase of the immersion time due to the appearance of cracks. The Bode diagram shows that there are two-time constants for the conversion films, in which the capacitive resistance rings at high frequency are ascribed to the conversion films and those at low frequency are the charge transfer reaction at the inner film and substrate interface.

**Table 4.** Fitted results of EIS parameters obtained on the TiO\(_2\) conversion films.

<table>
<thead>
<tr>
<th>Samples</th>
<th>(R_s) ((\Omega \text{ cm}^2))</th>
<th>(CPE_f)</th>
<th>(R_f) ((\Omega \text{ cm}^2))</th>
<th>(C_{dl})</th>
<th>(R_{ct}) ((\Omega \text{ cm}^2))</th>
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<td>T10</td>
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<td>5.0E-5</td>
<td>1800</td>
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<tr>
<td>T1800</td>
<td>1.0</td>
<td>9.4E-5</td>
<td>270</td>
<td>1.8E-3</td>
<td>750</td>
</tr>
</tbody>
</table>

**Figure 8.** Equivalent circuit schematizing the coating/NaCl solution interface of T10, T60, T300, and T1800.

From the above results, it can be concluded that the dense conversion film provides significant corrosion protection. To further explore the corrosion resistance of conversion films, equivalent circuits (ECs) are proposed based on Zview software, and the parameters of the equivalent circuit components are presented in Table 4. In this circuit (Fig. 8), \(R_s\) corresponds to the solution resistance, and the constant phase element \((CPE)\) is related to the double layer capacity of the solution/coating interface. \(R_f\) represents the charge transfer resistance occurring within the pores of the coating and on the surface, and \(C_{dl}\) represents the double layer capacitance. \(R_{ct}\) represents the resistance of the HDG substrate/coating interface due to the interaction between Zn-OH and Ti-O[31]. The results reveal that T60 has the lowest capacitance and highest resistance, indicating that it can effectively protect the zinc from corrosion.
3.4.2 Anti-corrosion performance of hydrophobic conversion films

The PDP curves for hydrophobic silane-modified conversion films are shown in Fig. 9, and the corresponding electrochemical parameters obtained from the PDP curves are listed in Table 5. Compared with the PDP results of TiO$_2$ conversion films, both the anodic and cathodic branches of polarization curves for hydrophobic conversion films shift towards the direction where the $i_{corr}$ decreases, indicating that the anodic process and cathodic process of zinc corrosion are inhibited after silane treatment. From the Table 5, it can be found that the $i_{corr}$ values of the hydrophobic conversion films decrease and the polarization resistance values increase compared with the TiO$_2$ conversion films.

![Figure 9. Potentiodynamic polarization curves for silane-modified conversion films in a 5 wt.% NaCl solution.](image)

**Table 5.** Electrochemical parameters obtained on the silane-modified conversion films

<table>
<thead>
<tr>
<th>Samples</th>
<th>$i_{corr}$ ($\mu$A/cm$^2$)</th>
<th>$E_{corr}$/V vs. SCE</th>
<th>$R_p$ (\Omega\cdot cm$^2$)</th>
<th>$b_a$ (mV/decade)</th>
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<td>45.32</td>
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<td>T1800M</td>
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<td>-0.996</td>
<td>4357</td>
<td>78.02</td>
<td>-20.39</td>
</tr>
</tbody>
</table>

The Nyquist and Bode diagrams for the hydrophobic conversion films in 5 wt.% NaCl are shown in Fig. 10. The total impedance values ($|Z|_{\omega=0}$) of T10M, T60M, T300M, and T1800M are 18600, 31160, 5635, and 1891 \Omega \cdot cm$^2$, respectively, which increase significantly compared to those of the T10, T60, T300, and T1800 films (Fig. 10a). The T10M, T60M and T300M is characterized by a
capacitive loop in the high, medium and low frequency range, which is related to the double conversion films and HDG substrate/coating interface. For the T1800M, the conversion film has partly peeled off, and the EIS result shows the corrosion behaviour as if the silane film covers part of the HDG surface. Simultaneously, there is an inductive loop in the low frequency range which is related to the dissolution of zinc is inductive loop of pitting corrosion of the HDG[32].

In view of the different EIS behaviours of the hydrophobic TiO$_2$ conversion films, different equivalent circuits used to fit the EIS spectra are shown in Fig. 11. For T10M, T60M, and T300M, the silane film covers the TiO$_2$ conversion film, a double conversion film has been formed on the HDG surface. Thus, $R_{f1}$ and CPE$_{f1}$ are added in the equivalent circuit as shown in Fig. 11a to fit T10M, T60M and T300M[33]. For T1800M, the two-time constant is used to fit T1800M, as shown in Fig. 11b.

Figure 10. EIS (a) Nyquist plots and (b) Bode plots (log $|Z|$ Vs log Freq and phase angle vs log Freq) for hydrophobic conversion films in a 5 wt. % NaCl solution.

Figure 11. Equivalent circuits schematizing the coating/NaCl solution of (a) T10M, T60M, and T300M; and (b) T1800M.

Table 6. Fitted results of EIS parameters obtained on the hydrophobic conversion films

<table>
<thead>
<tr>
<th>Sample</th>
<th>$R_s$ $(\Omega \text{ cm}^2)$</th>
<th>CPE$_f$ $Y_f$ $(\Omega^{-n} \text{ cm}^2)$</th>
<th>n$_f$</th>
<th>$R_f$ $(\Omega \text{ cm}^2)$</th>
<th>CPE$<em>{f1}$ $Y</em>{f1}$ $(\Omega^{-n} \text{ cm}^2)$</th>
<th>n$_{f1}$</th>
<th>$R_{ct}$ $(\Omega \text{ cm}^2)$</th>
<th>RL $(\Omega \text{ cm}^2)$</th>
<th>L $(\text{H/cm}^2)$</th>
</tr>
</thead>
<tbody>
<tr>
<td>T10M</td>
<td>1.1</td>
<td>3.5E-6</td>
<td>0.74</td>
<td>1081</td>
<td>4.6E-5</td>
<td>0.42</td>
<td>17325</td>
<td>0.0012</td>
<td>0.92</td>
</tr>
<tr>
<td>T60M</td>
<td>1.9</td>
<td>5.2E-6</td>
<td>0.77</td>
<td>290</td>
<td>1.1E-5</td>
<td>0.70</td>
<td>26000</td>
<td>8.62E-5</td>
<td>0.59</td>
</tr>
<tr>
<td>T300M</td>
<td>1.3</td>
<td>1.3E-6</td>
<td>0.78</td>
<td>504</td>
<td>1.6E-5</td>
<td>0.67</td>
<td>3068</td>
<td>0.00022</td>
<td>0.99</td>
</tr>
<tr>
<td>T1800M</td>
<td>0.2</td>
<td>5.0E-5</td>
<td>0.59</td>
<td>1050</td>
<td></td>
<td></td>
<td></td>
<td>0.00045</td>
<td>0.91</td>
</tr>
</tbody>
</table>
In the circuits, $R_s$ corresponds to the solution resistance; $R_f$ represents the charge transfer resistance of the hydrophobic conversion film; $R_{f1}$ represents the charge transfer resistance of the TiO$_2$ conversion film; $C_{dl}$ represents the double layer capacitance; and $R_{ct}$ represents the resistance of the HDG substrate/coating interface due to the interaction between Zn-OH and Ti-O. For T1800M, the $R_L$ and $L$ represent the inductive loop, which is related to the dissolution of zinc and is indicative of the pitting corrosion of the HDG, respectively. The fitted parameters are presented in Table 6. It is evident that T60M has the lowest capacitance and the highest resistance, indicating that it can effectively protect the zinc from corrosion.

The above experimental results have shown that the hydrophobic sealing of the silane on the TiO$_2$ conversion films could significantly improve the corrosion resistance of the samples. T60M has the best corrosion resistance because the double dense films are integrated. Even though the TiO$_2$ conversion films are peeled off, the filled silane film could have the effect of preservation, further protecting the HDG from corrosion.

![Figure 12](image)

**Figure 12.** EIS (a) Nyquist plots and (b) Bode plots (log |Z| Vs log Freq and phase angle vs log Freq) for hydrophobic TiO$_2$ conversion films in a 5 wt.% NaCl solution for one minute.

To explore the effect of hydrophobicity on the corrosion resistance of the films, the EIS experiments were conducted after the samples were immersed in NaCl solution for 1 min. The EIS results are shown in Fig. 12. It can be seen that during the early immersion stage, the T1800M film with the largest WCA shows the best corrosion resistance. Therefore, after modification by silane, the hydrophobicity of the films was better, and thus, the corrosion resistance of the coatings was better at the initial stage of immersion. This is because there is an unstable air layer on the surface, which results in the increase of the corrosion resistance of the coatings[34]. However, according to the EIS data, when the unstable air layer was destroyed, the corrosion resistance of the films decreased after a short period of immersion which is similar to previous reports[35]. The results demonstrate that the hydrophobicity of the films could increase the corrosion resistance of the samples. The T60 and T60M have the best corrosion resistance, respectively, indicating that the corrosion resistance of the composite film is mainly determined by the corrosion resistance of the TiO$_2$ conversion film. However, the corrosion resistance of the film increases after silane modification. The corrosion
resistance of silane-modified conversion film for short time immersion is determined by the water repellency of conversion film. However, the long-time immersion of corrosion resistance is determined by the conversion film.

4. CONCLUSION

The conversion film with Ti(OH)$_4$/TiO$_2$ and Zn(OH)$_2$/ZnO was prepared on the HDG surface by a one-step impregnation method. The Ti(OH)$_4$/TiO$_2$ aggregates into particles that cover or embed into the Zn(OH)$_2$/ZnO layer. The roughness of film increased with increasing passivation time. The corrosion resistance of the conversion film was first enhanced and decreased later with the increase of the passivation time. The integrated conversion film showed better corrosion resistance. After the silane hydrophobic sealing treatment, a layer of silane covered the conversion film, and the water repellence of the conversion film changes from hydrophilic to hydrophobic, which results in the increased corrosion resistance of the coatings. Therefore, the greater the roughness of conversion film, the better its hydrophobicity. The corrosion resistance of the film was not only related to the hydrophobicity but was also mainly determined by the TiO$_2$ conversion film.

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References


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